Electrochemical-Reaction-Driven Interfacial Stress in a Solid-Solid Layered Architecture
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Phys. Rev. Applied 11, 034038 — Published 15 March 2019
DOI: 10.1103/PhysRevApplied.11.034038
Electrochemical Reaction Driven Interfacial Stress in a Solid/Solid Layered Architecture

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Revised manuscript submitted to

Physical Review Applied

January 2019

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Abstract

Reaction driven interfacial growth causes significant strain in layered architectures accompanied by mass transfer and moving boundaries. Here, we present an analytical construct of the stress generated in a multi-layer film which incorporates the elastic-plastic strain of the growth layer, which suggests its strong dependence on the mechanical properties and thickness. This analytical formalism is further applied to a layered all-solid-state lithium battery architecture. This study demonstrates that mechanical stability can be enhanced by using a positive electrode material with high stiffness, porous hosts for lithium plating, and small external elastic constraints to buffer the volumetric changes in the electrode material. Our results also reveal that small surface flaws in the solid electrolyte and high internal hydrostatic pressure can alleviate lithium dendrite growth through surface cracks.

Keywords: Interfacial growth, multilayer film, all-solid-state Li battery, stress, fracture
I. INTRODUCTION

Layered, functional architectures have attracted intensive research interest, in emerging engineering applications, such as flexible electronics [1], gas separation [2], and energy storage [3]. The thickness of multilayer film could range from a few nanometers to millimeters, such as heteroepitaxial superlattice, coating, and laminated composite. In practical applications, each layer plays a unique role for special functions [4-6]. The damage of one layer could result in part or even catastrophic failure of the multilayer film. For batteries, the fracture of electrode exacerbates capacity fade, while the damage of separator could cause short circuit and explosion.

Mechanical stability is of great significance to ensure the robust performance of multilayer film. Under the operating conditions, multilayer films could be subject to large stresses, which leads to the failure of the film. Therefore, many efforts have been made to model the stress and reveal the failure mechanisms [7,8], including material fracture and film buckling. For instance, given that the interface was susceptible to environmentally-assisted subcritical debonding, the interfacial fracture resistance was quantitatively measured [9]. Theoretical models were developed to study the thermal stress in multilayer thin films, which provided guidance on the physical design of layered electronics [10,11]. The mechanics of ridge-cracked buckle delamination for compressed multilayers on curved substrates was established, which was applied to thermal barrier systems [12].

Physicochemical reactions could occur at the interfaces in a multilayer film, such as interfacial corrosion and metal electrodeposition, resulting in a new growth layer. In
the presence of the new interfacial layer, the initial stress field will be significantly changed in the confined space. For instance, multilayer films are used in energy storage systems [13], for example in all-solid-state lithium batteries, which have the layered structure of negative electrode, solid electrolyte separator, and positive electrode. In addition to the interfacial metal electrodeposition, the mass transfer also causes volumetric changes in electrodes. Recently, stresses were experimentally measured for all-solid-state batteries [14]. However, previous studies primarily focused on diffusion induced stresses at the electrode level [15-17], while the mechanics needs to be established for the novel multilayer film, which involves interfacial growth between different layers.

To this end, we first develop a simple theoretical model to analytically obtain the stresses in multilayer film, which stems from the interfacial growth layer and mass transfer. The elastic-plastic strain of the growth layer is considered. As an application, the developed model is used to investigate the mechanisms of Li plating induced stress in all-solid-state Li metal battery, which mainly consists of a layered structure of lithium metal, solid electrolyte separator, and a positive electrode film [18,19]. Mechanical failure is one of the critical degradation mechanisms of Li-ion batteries [20]. Based on our model, strategies are proposed which can facilitate releasing the interfacial build-up and avoid crack formation in the positive electrode and solid electrolyte. This study provides fundamental understanding of lithium plating induced stress in an all-solid-state Li metal battery, and suggests potential strategies to buffer volume changes in the electrode solid electrolyte and electrode layers which could
potentially avoid mechanical failures.

II. INTERFACIAL GROWTH INDUCED STRESS IN A LAYERED ARCHITECTURE

Linear elastic analysis

Fig. 1 illustrates a layered structure, comprised of \( N \) film layers. Due to the driving force, species (named \( A \) below) escape from the reservoir of the \( N \)th film and transport across the layered structure. Upon the arrival at the interface between Layer 1 and Layer 2, \( A \) is deposited under chemical (electrochemical) reactions or physical adsorption, leading to the formation of Layer 0. Because of the transfer of \( A \), the multilayer film significantly undergoes volume changes, which originate from two parts: contraction of Layer \( N \) and expansion of Layer 0. As the release of \( A \) from the reservoir continues, the \( N \)th layer is gradually shrunk. Conversely, the thickness of Layer 0 increases during \( A \) deposition. Consequently, the volume changes produce built-in stresses across the system.

Here, the three directions are denoted by \( x \), \( y \), and \( z \), with \( y \) in the direction normal to the film (thickness direction). Layers are assumed to be well contacted during \( A \) transfer, without the interfacial slip and delamination. As a result, there are no shear stresses, and the three principal stresses are \( \sigma_{xx} \), \( \sigma_{yy} \), and \( \sigma_{zz} \).

First, we assume that all the materials experience elastic deformations. In the regime of isotropic linear elasticity, the constitutive equations read
\[ \varepsilon_y = -\frac{\nu}{E} \sigma_{yy} + \frac{1+\nu}{E} \sigma_y. \] (1)

\( \varepsilon_y \) is the strain tensor and \( \sigma_y \) is the stress tensor. \( \delta_y \) is the Kronecker delta. All the indices run from \( x \) to \( z \), corresponding to the three directions, and the repeated index \( k \) implies summation. \( E \) is the Young’s modulus and \( \nu \) is the Poisson’s ratio.

For the \( N \)th layer, the constitutive equations are revised as [21]

\[ \varepsilon_y = -\frac{\nu}{E} \sigma_{yy} + \frac{1+\nu}{E} \sigma_y - \varepsilon_0 \delta_y. \] (2)

where the last term \( \varepsilon_0 \) is the eigenstrain, accounting for the volume shrinkage after the release of \( A \) from the \( N \)th layer, which is expressed by

\[ \varepsilon_0 = (V_c + 1)^\frac{1}{3} - 1, \]

\[ V_c = \frac{V_0 - V}{V_0} = (c_0 - c) \Omega_N, \] (3)

where \( V_c \) represents the volume strain. \( V_0 \) is the reference volume of the \( N \)th film and \( V \) is the current volume. \( c \) is the concentration in the \( N \)th layer, \( c_0 \) is the reference concentration, and \( \Omega_N \) is the partial molar volume of \( A \) in the \( N \)th layer.

Given that the thickness of each layer is much smaller than the sizes in the other two directions, the strains in the directions \( x \) and \( z \) are neglected, which is similar to the case of plane strain. Thus, we have

\[ \varepsilon_{xx} = \varepsilon_{zz} = 0, \] (4)

\[ \sigma_{xx} = \sigma_{zz}. \] (5)

Substituting Eqs. (5) into Eqs. (1) and (2) separately, and then using Eq. (4), we can get

\[ \sigma_{xx} = \sigma_{zz} = \frac{\nu}{1-\nu} \sigma_{yy}, \] (6)

\[ \sigma_{xx} = \sigma_{zz} = \frac{\nu}{1-\nu} \sigma_{yy} + \frac{1}{1-\nu} \varepsilon_0. \] (7)

Eq. (6) is valid for Layer 0 to Layer \( N-1 \), and Eq. (7) is for the \( N \)th layer. Substituting
the two equations back into Eqs. (1) and (2), respectively, we obtain
\[ e_{yy} = \frac{1 - 2\nu}{E(1 - \nu)} \sigma_{yy}, \]  
(8) \[ e_{yy} = \frac{1 + \nu}{E(1 - \nu)} (1 - \nu) \sigma_{yy} \]  
(9)

Hence, the derived constitutive equationsconcisely relate the strain to the stress in the
y-axis direction.

Due to the reactions at the interface between the first two layers, the transfer of \( A \)
from the \( N \)th layer leads to a moving reaction front. The increased thickness at the
interface is given as
\[ l_o = \frac{(c_0 - c) \nu \Omega_d}{S} \]  
(10) \[ = (c_0 - c) \nu \Omega_d l_N = \frac{\Omega_d V_c l_N}{\Omega_N}, \]
where \( V_0, S, \) and \( l_N \) are the volume, cross-sectional area, and thickness of the \( N \)th layer,
respectively, and \( \Omega_d \) is the molar volume of substance \( A \).

In the \( y \)-axis direction, the total thickness of the system is assumed to be constant,
which satisfies that
\[ l_o + e_{yy} l_i + \Delta l_{N+1} = 0, \]
(11) where \( i \) runs from 0 to \( N, l_i \) is the thickness of Layer \( i, e_{yy} \) is the \( y \)-axis strain of Layer
\( i, \) and \( \Delta l_{N+1} \) denotes the thickness change of other surrounding components. We have
that \( \Delta l_{N+1} = F / k = \sigma_{yy} S / k = \sigma_{yy} l_i (k / S) = \sigma_{yy} / K \), where \( F \) is the total force in the
thickness direction, \( k \) is the effective spring constant applied to the layered structure
from the surroundings, and \( S \) is the effective area. Thus, \( K \) is interpreted as the effective
stiffness per area (the required stress under the thickness change of 1 \( \mu \)m), which could
be affected by other battery components, such as the current collector, internal spring,
metal shell, etc. If the multilayer film is subject to rigid constraints, \( \Delta l_{N+1} \) is equal to
zero. Note also that each layer has the same stress in the thickness direction

\[ \sigma_{yy} = \sigma_{yys}. \] (12)

Upon the substitution of Eqs. (8), (9), and (12) into Eq. (11), the stress in the thickness direction is solved as

\[ \sigma_{yy} = \left[ \sum_{i=0}^{N} \frac{(1-2\nu_i)(1+\nu_i)}{E_i(1-\nu_i)} l_i + \frac{1}{K} \right]^{-1} \left( \frac{1+\nu_N}{1-\nu_N} \varepsilon_{0N} l_N - l_0 \right). \] (13)

Subsequently, the stresses in the \( x \)-axis and \( y \)-axis directions can be obtained by Eqs. (6) and (7).

In the multilayer film, releasing stress can avert structural failures. An ideal condition is that the stress in the thickness direction is zero, which requires that the expansion of the interface layer is well compensated by the contraction of the \( N \)th layer.

From Eq. (13), it is evident that

\[ \frac{1+\nu_N}{1-\nu_N} \varepsilon_{0N} l_N - l_0 = 0. \] (14)

Using Eqs. (3) and (10), the above equality is rephrased as

\[ \frac{\Omega_d}{\Omega_N} = \frac{1+\nu_N}{1-\nu_N} \frac{1}{V_c} \left[ \left( V_c + 1 \right)^3 - 1 \right]. \] (15)

On the right hand, \( \nu_N \) and \( V_c \) are both physical parameters of the \( N \)th film. If \( V_c \) is infinitesimal (compared to 1), Eq. (15) is reduced to

\[ \frac{\Omega_d}{\Omega_N} = \frac{1+\nu_N}{3(1-\nu_N)}. \] (16)

In essence, no stress is produced in the thickness direction if the material parameters satisfy Eq. (15). Fig. 2 illustrates the map of \( \Omega_d / \Omega_N \) in terms of the
Poisson’s ratio and the volume strain of the Nth layer. It can be seen that regardless of $\nu_N$ and $V_c$, $\Omega / \Omega_N$ is always less than one.

**Elastic-plastic analysis**

If $A$ is a ductile material, for instance metal, the interfacial growth layer will experience plastic deformation when stress reaches its initial yield strength. Therefore, the elastic-plastic behavior needs to be taken into account. In the following, we assume that Layer 0 and Layer 1 have the same ductile material $A$, and other layers are brittle materials. For Layer 1 (Layer 0 included), Eq. (1) is rewritten as

$$\varepsilon_{y_1} = -\frac{\nu_1}{E_1}\sigma_{x_{x1}}\delta_{y} + \frac{1+\nu_1}{E_1}\sigma_{y_{y1}} + \varepsilon_{y_1}^p. \quad (17)$$

The strain tensor is decomposed into elastic and plastic parts, where the last term is the plastic strain. Given that plastic deformation does not affect the volume change, we have [22]

$$\varepsilon_{x_{x1}}^p + \varepsilon_{y_{y1}}^p + \varepsilon_{x_{x1}}^p = 0, \quad (18)$$

where $\varepsilon_{x_{x1}}^p$, $\varepsilon_{y_{y1}}^p$, and $\varepsilon_{x_{x1}}^p$ are the three components of plastic strain in the three directions. Set that the plastic strain in the film thickness direction is $\varepsilon_{x_{x1}}^p$, we can get $\varepsilon_{y_{y1}}^p = \varepsilon_{y_{y1}}^p$ and $\varepsilon_{x_{x1}}^p = -\varepsilon_{x_{x1}}^p / 2$. In view of Eqs. (4), (5), and (17), it gives

$$\frac{1}{E_1}\left[(1-\nu_1)\sigma_{x_{x1}} - \nu_1\sigma_{y_{y1}}\right] - \frac{1}{2}\varepsilon_{x_{x1}}^p = 0, \quad (19)$$

$$\frac{1}{E_1}\left(\sigma_{y_{y1}} - 2\nu_1\sigma_{x_{x1}}\right) + \varepsilon_{y_{y1}}^p = \varepsilon_{y_{y1}}. \quad (20)$$

To solve the stress, we need one more equation, namely the yield criterion.

For a ductile material, von Mises criterion is the most frequently utilized yield
criterion [22], which takes the form

\[ J_2 = \frac{1}{2} s_{ij} s_{ij} = k^2. \]  

(21)

\( k \) is the material parameter, which is a function of plastic deformation history. \( J_2 \) is the second invariant of the deviatoric part of stress tensor \( s_{ij} \), which is defined as \( s_{ij} = \sigma_{ij} - \sigma_{kk} \delta_{ij} / 3 \). In terms of the principal stresses in Layer 1, \( J_2 \) is expressed as

\[ J_2 = \frac{1}{6} \left[ (\sigma_{xx} - \sigma_{yy})^2 + (\sigma_{yy} - \sigma_{zz})^2 + (\sigma_{zz} - \sigma_{xx})^2 \right]. \]  

(22)

In general, uniaxial tension is used to obtain \( k(\bar{\varepsilon}^p) \), where \( \bar{\varepsilon}^p \) is the effective plastic strain. From the stress-strain curve, the yield stress is deduced as a function of plastic strain: \( \bar{\sigma}(\bar{\varepsilon}^p) \). We have

\[ k = \frac{\bar{\sigma}(\bar{\varepsilon}^p)}{\sqrt{3}}. \]  

(23)

For Layer 1, the stress state is different from uniaxial tension. Using \( \varepsilon_{yy1}^p = \varepsilon^p \) and \( \varepsilon_{xx1}^p = \varepsilon_{zz1}^p = -\varepsilon^p / 2 \) for the current case, the effective plastic strain is given as

\[ \bar{\varepsilon}^p = \int (\frac{2}{3} D_{ij}^p D_{ij}^p)^{1/2} \, dr = \int (\frac{2}{3} d\varepsilon_{ij}^p d\varepsilon_{ij}^p)^{1/2} = |\varepsilon^p|, \]  

(24)

where \( D_{ij}^p \) is the plastic rate of deformation. As a result, if Layer 1 is compressed (\( \sigma_{yy1} < 0 \)), the effective plastic strain is equal to the opposite of the plastic strain in the thickness direction. When Eqs. (22) and (23) are incorporated into Eq. (21), it follows that

\[ (\sigma_{yy1} - \sigma_{xx1})^2 = \bar{\sigma}^2(\bar{\varepsilon}^p) = \bar{\sigma}^2 (|\varepsilon^p|). \]  

(25)

Combining Eqs. (19) with (25) and then using Eq. (20), we can finally establish the relation between \( \varepsilon_{yy1} \) and \( \sigma_{yy1} \) with the effect of plasticity in Layer 1. Nevertheless, the relation depends on the yield stress \( \bar{\sigma}(\bar{\varepsilon}^p) \) measured in uniaxial tension.
For simplicity, linear isotropic hardening model is used. Therefore, we assume that the stress-strain curve in uniaxial tension has two linear parts. After stress exceeds the initial yield stress, the new yield stress is expressed as

$$\bar{\sigma} = E_0^0 \left( \frac{\varepsilon}{E} - \frac{\sigma_s}{E} \right) + \sigma_s. \quad (26)$$

$E$ is the Young’s modulus, $E_0^0$ is the tangent modulus (slope) after the initial yield, and $\sigma_s$ is the initial yield stress. Strain $\varepsilon$ is the sum of elastic and plastic parts, i.e.

$$\varepsilon = \frac{\bar{\sigma}}{E} + \varepsilon_p. \quad (27)$$

The substitution of Eq. (27) into Eq. (26) gives

$$\bar{\sigma} = \frac{E E_0^0}{E - E_0^0} \varepsilon_p + \sigma_s. \quad (28)$$

$EE_0^0(E-E_0^0)$ is physically interpreted as the plastic modulus.

Thus, Eq. (19) is rewritten as

$$\sigma_{n1} = \left[ 1 + \frac{2E_0^0}{E_1 - E_0^0} (1 - \nu_1) \right]^{-1} \left[ \left( 1 + \frac{2E_0^0}{E_1 - E_0^0} \nu_1 \right) \sigma_{y1} + \sigma_s^0 \right]. \quad (29)$$

where

$$\sigma_s^0 = \begin{cases} \sigma_s, & \sigma_{y1} < 0 \\ -\sigma_s, & \sigma_{y1} > 0 \end{cases}. \quad (30)$$

The substitution of Eqs. (19) and (29) into (20) yields

$$\varepsilon_{y1} = \frac{1 - 2\nu_1}{E_1} \left[ 2 \left( 1 + \frac{2E_0^0}{E_1 - E_0^0} \nu_1 \right) \left( 1 + \frac{2E_0^0}{E_1 - E_0^0} (1 - \nu_1) \right)^{-1} + 1 \right] \sigma_{y1} + 2 \frac{1 - 2\nu_1}{E_1} \left( 1 + \frac{2E_0^0}{E_1 - E_0^0} (1 - \nu_1) \right)^{-1} \sigma_s^0. \quad (31)$$

Similar to the procedure used to obtain Eq. (13), the stress in the thickness direction is solved as


\[
\sigma_{yy} = C_1 \left[ \frac{1}{C_2} (l_i + l_0) + \sum_{i=2}^{N} \frac{(1-2\nu_i)(1+\nu_i)}{E_i(1-\nu_i)} l_i + \frac{1}{K} \right],
\]  

(32)

where

\[
C_1 = \frac{1+\nu_3}{1-\nu_3} e_{0/3} - l_0 - 2 \frac{1-2\nu_1}{E_1} \left[ 1 + \frac{2E_0^0}{E_i - E_1^0} (1-\nu_1) \right]^{-1} \sigma_i^0 (l_i + l_0),
\]  

(33)

\[
\frac{1}{C_2} = \frac{1-2\nu_1}{E_1} \left\{ 2 \left[ 1 + \frac{2E_0^0}{E_i - E_1^0} \nu_1 \right] \left[ 1 + \frac{2E_0^0}{E_i - E_1^0} (1-\nu_1) \right]^{-1} + 1 \right\}.
\]  

(34)

Correspondingly, other stresses can be analytically solved by using constitutive equations. If non-linear isotropic hardening is assumed, a non-linear relationship between \( \bar{\sigma} \) and \( \bar{\varepsilon} \) will be presented in Eq. (26). The stress in the thickness direction \( \sigma_{yy} \) could also be obtained by numerical calculations.

III. APPLICATION TO ALL-SOLID-STATE LI BATTERY

The model is applied to all-solid-state Li battery, of which the multilayer film is comprised of the Li metal film (Layer 1), solid electrolyte separator (Layer 2), and positive electrode film (Layer 3). Li-ions diffuse out of the positive electrode film and transport across the solid electrolyte separator. Upon the arrival at the solid electrolyte-Li interface, Li-ions are reduced and then deposited on the negative electrode surface. As the deintercalation of Li-ions from the positive electrode continues, the positive electrode film is gradually shrunk. Conversely, the thickness of Li metal increases during Li plating.

For Li metal, the molar volume is \( 1.3 \times 10^{-5} \text{ m}^3 \text{ mol}^{-1} \) [23,24]. If the positive electrode material is LiMn_2O_4, the partial molar volume of Li-ion is \( 3.5 \times 10^{-6} \text{ m}^3 \text{ mol}^{-1} \).
Obviously, Eq. (15) does not hold for the use of LiMn$_2$O$_4$. For Li$_2$S, the electrochemical reactions are

$$\text{Li}_2\text{S} \rightarrow \frac{1}{8}\text{S}_8 + 2\text{Li}^+ + 2e^-.$$  \hspace{1cm} (35)

When the reaction proceeds from the left to the right, the volume contraction of Li$_2$S is about 44%. Considering that the molar volumes of S$_8$ and Li$_2$S are $1.239 \times 10^{-4}$ m$^3$ mol$^{-1}$ and $2.768 \times 10^{-5}$ m$^3$ mol$^{-1}$ [26], the partial molar volume of Li-ion in Li$_2$S is readily calculated as $6.1 \times 10^{-6}$ m$^3$ mol$^{-1}$. Thus, Eq. (15) does not hold. For conventional positive electrodes, such as LiCoO$_2$, LiMn$_2$O$_4$, and LiFePO$_4$, the Poisson’s ratio ranges from 0.24 to 0.32, and the volume strain ranges from 2% to 6.8% [27]. For the positive electrode Li$_2$S, the volume strain is 44% when Li$_2$S is oxidized to S during Li plating on the negative electrode. Thus, the Poisson’s ratios and volume strains of most positive electrodes are within the ranges considered in Fig. 2. For Li metal film, Eq. (15) could not be satisfied because of the relatively larger molar volume of Li compared with the partial molar volumes of Li-ion in common positive electrode materials. As a result, stresses are generated in the layered film.

In the regime of elasticity, stress is given by Eq. (13). However, Li metal experiences both elastic and plastic deformations when the yield criterion in Eq. (21) is satisfied. If Li metal is considered as a linear isotropic hardening material, stress is analytically solved in Eq. (32). The solid electrolytes and electrodes are assumed to be homogeneous. Considering Li-oxides on Li metal is much thinner than the metal electrode, their influences on the mechanics of our model are neglected. Unless otherwise indicated, we use the material parameters listed in Table 1 [10,23,25,28,29],
with Li$_2$S-P$_2$S$_5$ used as the solid electrolyte, and set that $l_1 = 10$ μm, $l_2 = 25$ μm, $l_3 = 70$ μm, and $K_4 = 50$ MPa μm$^{-1}$.

**Table 1. Material Parameters**

<table>
<thead>
<tr>
<th>Parameters</th>
<th>Li</th>
<th>Solid electrolyte</th>
<th>Positive electrode</th>
<th>Units</th>
</tr>
</thead>
<tbody>
<tr>
<td>$E$ Young’s modulus</td>
<td>1.9</td>
<td>20</td>
<td>10</td>
<td>GPa</td>
</tr>
<tr>
<td>$v$ Poisson’s ratio</td>
<td>0.42</td>
<td>0.3</td>
<td>0.3</td>
<td></td>
</tr>
<tr>
<td>$\sigma_s$ Initial yield stress</td>
<td>0.53</td>
<td></td>
<td></td>
<td>MPa</td>
</tr>
<tr>
<td>$E^t$ Tangent modulus ($\sigma &gt; \sigma_s$)</td>
<td>17.1</td>
<td></td>
<td></td>
<td>MPa</td>
</tr>
<tr>
<td>$\Omega$ (Partial) Molar volume</td>
<td>$1.3 \times 10^{-5}$</td>
<td>$4.5 \times 10^{-6}$</td>
<td>m$^3$ mol$^{-1}$</td>
<td></td>
</tr>
<tr>
<td>$V_c$ Volume strain</td>
<td></td>
<td></td>
<td>0.05</td>
<td></td>
</tr>
</tbody>
</table>

Fig. 3 shows the three principal stresses of the positive electrode, solid electrolyte separator, and Li metal. Because the thickness increase of Li metal is larger than the thickness decrease of the positive electrode film, the multilayered structure is prone to expansion, leading to a compressive stress in the thickness direction. As Li plating proceeds, the growing Li generates a larger compressive stress $\sigma_{yy}$. In the x-axis and z-axis directions, Li metal and solid electrolyte separator are also subject to compressive stresses. For Li metal film, the curves of the three principal stresses almost overlap when Li plasticity is considered, producing a triaxial compressive stress state. In contrast, the solid electrolyte separator has relatively smaller compressive stresses $\sigma_{xx}$ and $\sigma_{zz}$ in comparison to $\sigma_{yy}$. Based on our results, solid electrolytes undergo stress in the confined space of all-solid-state batteries, and the stress could affect ionic transport.
in the solid electrolytes, as demonstrated in previous studies [30,31]. Thus, further efforts are needed to examine the roles of stress on ionic conduction of solid electrolytes and battery performance. For the positive electrode film, tensile stresses are generated in the $xz$ plane as opposed to the compressive stress in the thickness direction. The stretching effect is due to the contribution from the delithiation-induced eigenstrain $\varepsilon_o$ in the positive electrode, as shown in Eq. (7).

Fig. 3(b) shows the stress difference $\sigma_{sei}-\sigma_{jo}$ of Li metal in the early Li plating. Obviously, there are two stages. Li metal film deforms elastically when $V_t/V_c$ is extremely small. As the stress difference exceeds the initial yield stress of 0.53 MPa, the material begins to yield, leading to elastic-plastic deformations. Owing to the plastic strain hardening, the yield strength linearly increases. Therefore, the stress difference gradually increases with growing Li metal thickness.

Next, the influences of material parameters on stress are examined. For Eq. (13) or (32), we can define

$$\frac{1}{K_1} = \frac{(1-2\nu_1)(1+\nu_1)}{E_1(1-\nu_1)} l_1, \quad \frac{1}{K_2} = \frac{(1-2\nu_2)(1+\nu_2)}{E_2(1-\nu_2)} l_2, \quad \frac{1}{K_3} = \frac{(1-2\nu_3)(1+\nu_3)}{E_3(1-\nu_3)} l_3. \tag{36}$$

$K_1$, $K_2$, and $K_3$ are the elastic stiffness coefficients of the Li metal film, solid electrolyte separator, and positive electrode film, respectively, which are a combination of mechanical properties and thickness. In the following, $K_3$ is varied by changing the Young’s modulus of the positive electrode, and $K_4$ is also varied. For Li metal and solid electrolyte, the material parameters remain the same as those in Table 1.

Fig. 4(a) shows the stress difference $\sigma_{jo}$ in terms of $K_3/K_1$ and $K_4/K_1$. The
compressive stress $\sigma_{yy}$ increases with increasing $K_3/K_1$ and $K_4/K_1$. In contrast, Fig. 3(b) show a different map for the stress $\sigma_{xx}$ ($\sigma_{zz}$) of the positive electrode film. $\sigma_{xx}$ increases with increasing $K_3/K_1$ and decreasing $K_4/K_1$. Interestingly, as $K_3/K_1$ decreases, $\sigma_{xx}$ can be transitioned from tensile stress to compressive stress. In Eq. (7), the competition between the two terms on the right hand governs the value of $\sigma_{xx}$. The first term is negative, while the second term is positive. As the Young’s modulus of the positive electrode decreases, the values of the two terms both decreases. However, the decrease of the second term is larger than that of the first term, which eventually results in a compressive stress.

For Li metal, plastic deformation occurs when the von Mises criterion is satisfied. On the other side, the materials in other layers are considered as brittle materials, and the fracture is assumed to obey the maximum shear stress criterion [22]

$$\frac{1}{2} \max \left( |\sigma_{xx} - \sigma_{yy}|, |\sigma_{yy} - \sigma_{zz}|, |\sigma_{zz} - \sigma_{xx}| \right) = \sigma_F,$$

(37)

Where $\sigma_F$ is the critical stress.

By using the criterion, Figs. 5(a) and (b) show the phase maps of mechanical stability for the positive electrode and solid electrolyte separator, respectively, where the yield stress is assumed to be 1.5 percent of Young’s modulus in this study, $\sigma_F = 0.015 \, E$. The blue represents safe zone and the white denotes failure zone. For a fixed $K_3/K_1$, reducing $K_4/K_1$ is beneficial to the mechanical stability of the positive electrode. Inversely, for a fixed $K_4/K_1$, increasing $K_3/K_1$ can avoid the failure of the positive electrode film. In Fig. 5(b), the solid electrolyte separator fails under the conditions that both $K_3/K_1$ and $K_4/K_1$ are large. In addition, Fig. 5(c) shows the combined phase map,
where the blue indicates the shared safe zone for the positive electrode film and solid electrolyte separator. $K_d/K_1$ is less than 1.75 in the safe zone, which indicates that the constraint on the layered structure should be weak. In Fig. 5(d), the stress difference $\sigma_{xx} - \sigma_{yy}$ of Li metal is illustrated. If $K_d/K_1$ is very small, Li metal only experiences elastic deformation during Li plating, since the large volume changes of electrode films are buffered by the surroundings.

In the above analysis, Li is electrodeposited on Li metal, and thus, $\Omega_{Li}$ is set to $1.3 \times 10^{-5}$ m$^3$ mol$^{-1}$ [23]. If Li is deposited into porous hosts [32], the volume change will be significantly reduced, leading to a smaller $\Omega_{Li}$. Therefore, the effect of $\Omega_{Li}$ on stress is studied, as shown in Fig. 6. Three specific cases are chosen: $K_3/K_1 = 1$ and $K_d/K_1 = 0.05$, $K_3/K_1 = 1$ and $K_d/K_1 = 0.5$, and $K_3/K_1 = 4$ and $K_d/K_1 = 2$. With varying $\Omega_{Li} / \Omega_{Li'}$, the three cases are denoted by the black, red, and blue lines in Fig. 6, respectively. It can be seen that as $\Omega_{Li} / \Omega_{Li'}$ decreases, the failures of the positive electrode film and solid electrolyte separator does not occur when $\left( \sigma_{xx} - \sigma_{yy} \right) / 2\sigma_F$ is reduced below one in Fig. 6(a). For porous hosts, $\Omega_{Li}$ is allowed to be smaller than Li molar volume. Fig. 6(b) demonstrated that there is no stress generated in the thickness direction when Eq. (16) is satisfied ($V_c$ is 0.05, much smaller than 1.0). As $\Omega_{Li} / \Omega_{Li'}$ continues to decrease, the thickness reduction of the positive electrode film is less than the thickness increase of Li, thereby causing a tensile stress of $\sigma_{yy}$.

In addition, Li dendrite growth can produce local stresses and electrochemical potential changes, which induce crack propagation and even short circuit. Li dendrite could penetrate the solid electrolyte separator through the surface flaws of solid
electrolytes, like surface pre-existing cracks and grain boundaries [33]. Here, the edge crack model is used to simplify the problem. In Fig. (7), the green is the solid electrolyte, the white is a surface crack, and the gray is Li dendrite. At the dendrite-electrolyte interface (crack surface), Li-ions are reduced, and the electrodeposited Li atoms can diffuse over the dendrite surface (the dashed line). Because of the expansion of Li dendrite inside the crack, we assume that the crack is subject to a uniformly distributed pressure of \( p \). As the pressure increases, the crack-tip could be forced to advance, thereby favoring the dendrite growth through the solid electrolyte separator.

Considering the stress \( \sigma_{xx} \) in the vertical direction, the stress intensity factor is given by [34]

\[
K_I = 1.12 \left( p - |\sigma_{xx}| \right) \sqrt{\pi a}.
\]  
(38)

Here, \( \sigma_{xx} \) is negative. The crack growth requires that

\[
K_I \geq K_{ic},
\]  
(39)

where \( K_{ic} \) is the fracture toughness of solid electrolyte, which can be measured from experiments. For Li\(_2\)S-P\(_2\)S\(_5\) (LPS) and Li\(_7\)La\(_3\)Zr\(_2\)O\(_12\) (LLZO), \( K_{ic} \) are 0.23 and 1.25 MPa m\(^{1/2} \), respectively [35,36]. Fig. 7 illustrates the crack length dependent critical stress that causes the crack propagation and thus Li dendrite growth. Based on Fig. 7, there are three strategies to alleviate Li dendrite penetration through solid electrolytes.

Compared with LPS, LLZO has a higher critical stress due to its relatively larger fracture resistance. Therefore, enhancing the fracture toughness of solid electrolyte helps to suppress Li dendrite growth through the solid electrolyte separator. Increasing fracture toughness contributes to the suppression of Li dendrite growth through solid
electrolytes, however, it could also cause the reduction in ionic conductivity [38], which also applies to the comparison of LPS and LLZO. Thus, a trade-off could exist for the use of solid electrolytes with high fracture toughness, and a balance is needed to achieve high performance of all-solid-state batteries. The size of surface flaw plays a key role in determining the crack opening. The critical stress is significantly reduced with increasing length of surface flaw, and thus, the crack can propagate under a lower pressure from Li dendrite. In turn, the growing dendrite fills the void of new crack. To avoid the crack growth, we can reduce the density and size of surface defects, such as polishing the separator surface and coating the separator with a dense and defect-free layer. In addition, it can be seen that the pressure $p$, originating from Li dendrite expansion, needs to overcome the stress $\sigma_{xc}$ for the crack growth. In literature, applying a pressure inside the battery was reported as an effective method to improve Li electrodeposition [37].

**IV. CONCLUSION**

In summary, we develop a theoretical model of interfacial growth induced stress in the multilayer film, which enables us to analytically obtain the stresses. In this model, the elastic-plastic deformation of the growth layer is considered. The model demonstrates that stresses largely depend on the elastic properties and thicknesses of all the layers in the system. A concise formula is deduced for a particular case that no stress is produced in the film thickness direction. The model is applied to investigate the mechanical behaviors of the layered structure of Li metal-separator-positive
electrode in all-solid-state battery. Based on our results, we can draw the conclusions as follows. (1) In the early stage of Li plating, the Li metal electrode undergoes elastic deformation. To avoid the failure of materials, the positive electrode film needs to have high stiffness, and the external elastic constraints on the multilayer film should be small to release the volumetric changes of electrode materials. (2) Stress can be significantly reduced by using porous hosts for Li electrodeposition due to relatively low Li molar volume. In practice, porous hosts could also increase the active sites and thus avoid Li dendrite growth at high current density. (3) Dendrite growth in the solid electrolyte is also analyzed. It is found that Li dendrite penetration through the solid electrolyte separator can be alleviated by increasing the fracture toughness of solid electrolytes, reducing surface flaw size, and applying internal battery pressure. In practical applications, Li$^+$ migration through solid electrolytes is driven by the gradient of the chemical potential, which could be affected by local defects. Thus, a mechanistic study is needed to explore the role of defects on Li$^+$ migration. In addition, a coupled model of mechanics-electrochemistry will be developed to understand the interactions between stress and Li$^+$ migration in our future work.

**ACKNOWLEDGEMENT**

The information, data, or work presented herein was funded in part by the Office of Energy Efficiency and Renewable Energy (EERE), U.S. Department of Energy, under Award DE-EE0007766, and Purdue University faculty research grant.
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FIGURES AND FIGURE CAPTIONS

FIG. 1. Schematic of the interfacial growth in a layered structure, consisting of N layers. The green represents a newly formed layer (Layer 0). A is transferred from the reservoir of Layer N and deposited at the interface between Layer 1 and Layer 2. After the mass transfer, the Nth layer contracts. K represents the external constraint stiffness applied to the layered structure. The right figure shows the stress state, with $y$-axis in the thickness direction (the horizontal direction).
FIG. 2. In terms of the Poisson’s ratio and volume strain of the $N$th layer, the calculated $\Omega_A/\Omega_N$ for the condition that no stress is generated in the film thickness direction.
FIG. 3. Stress evolution during Li plating, where $V_c$ is the maximum volume strain of the positive electrode and $V_t$ is the volume strain of the positive electrode during plating. (a) Stresses of the positive electrode film, solid electrolyte separator, and Li metal. (b) Stress difference in Li metal.
FIG. 4. In terms of $K_f/K_1$ and $K_d/K_1$, $\sigma_{yy}$ in the film thickness direction and $\sigma_{xx3}$ in the positive electrode film.
FIG. 5. For mechanical stability, the phase maps of (a) the positive electrode film and (b) solid electrolyte separator in terms of $K_3/K_1$ and $K/K_1$. (c) Combined phase map for the positive electrode film and solid electrolyte separator. The blue is safe zone, and the white is failure zone. (d) Stress differences of Li metal with varying $K_3/K_1$ and $K/K_1$. 
FIG. 6. Effect of $\Omega_{Li}/\Omega_{Li^+}$ on Li plating induced stress. (a) Stress for the positive electrode film and solid electrolyte separator. (b) Stress in the thickness direction.
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FIG. 7. For the solid electrolyte separators of LPS and LLZO, the critical stress, driving the crack propagation, depends on the length of surface flaw.